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APPLICATION DATA SHEET

Title: METHOD FOR MANUFACTURING COMPOUND SEMICONDUCTOR
EPITAXIAL SUBSTRATE

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Foreign Priority: This Application is the National Phase of International Application No. PCT/JP2004/016905 filed November 8, 2004, which designated the U.S. and was not published under PCT Article 21(2) in English, and this application claims, via the aforesaid International Application, the foreign priority benefit of and claims the priority from Japanese Application No. 2003-382116, filed November 12, 2003, the complete disclosures of which are incorporated herein by reference.